U.S. NAVAL RESEARCH LABORATORY

Institute for Nanoscience



The U.S. Navy, known for its enormous aircraft earriers and nuclear submarines, now has the opportunity to exploit the world of the very small for its next generation of technology. Future technology will be increasingly based upon materials and devices fabricated at the atomic scale (measured in nanometers – billionths of a meter). And because it understands

scientists with disparate training and backgrounds to attack common goals at the intersection of their leadership for the Navy and DOD to identify and exploit those cross-disciplinary opportunities at this length scale that had been previously inacces-

In support of this new initiative, NRL has constructed a major new facility at its Washington, DC location. The new facility, opened in October 2003, is administered by the Institute Director, It houses approximately 5,000 square feet of Class 100 fabrication clean rooms and an equal area of specialized, vibrationally and acoustically quiet and ultra-



CURRENT PROGRAMS

- Supramolecular photoelectronic nanodevice based on artificial photosynthetic model
- Quantum dot materials for non-linear optics Integrated nanomechanical device arrays.

- Nano-, Bio-, and Molecular Electronics - Assembly of laterally coupled
- Nanocluster electronics by macro-

- nanocluster-based electronics/sensors

FACILITIES

Field Emission Transmission Electron



Wafer Inspection Station

Reactive Ion Etching Systems

Metrology

4-Probe UHV STM

and Nano-

manipulator



Optical Mask Aligners



Scanning Electron



Focused Ion

Electron Beam

Lithography

Ion Beam

Electron-Beam

Evaporation

System

Deposition



RECENT SUCCESSES

Nanomaterials



Nanoarchitectures constructed by combining electrically con-ducting nanostructured solids paths. The exploration of such being and nothing-ness" is of materials and structures in other materials applications



Carbon nanotubes have been grown and selectively deposited by a dielectrophe resis method and under nagnetic control. Crystalline GaN nanowires have been

Instrumentation Research, Metrology, and Standards for Nanotechnology



the-world Nanomanipulation and Characterization Facility



Introduced a new model describing the writing mech anism for Dip Pen Nanolithography (DPN) and also invented the thermal DPN (tDPN) method in which nanostructures can be deposited or written directly onto a substrate by heating the tip of the device

Nanoscale Devices and Systems





Gold nanocluster particles



rod polymer templates to self-



Successfully synthesized an important photo electro active donor-acceptor chain chromophore combined with helical amylace for incorporation into photoelectronic (i.e.







Miniature OLEDs, some as small as 60 nanometers across, may prove useful for quantum communication or in photopatterning nanomaterials. The OLEDs rely on a light-emitting polymer called MEH-PPV. The polymer is packed inside cylindrical nanoholes etched about 100 nanometers deep into a film of silicon nitride. Each cylinder acts as an independent OLED. Tests showed that the nanodiode's electrical and light-emitting properties are much like those of a larger reference OLED.